



THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Jarmo Ilmari Maula et al.

Confirmation No. 6738

Application No. 10/609,134

Filed: June 26, 2003

For: **HIGH-SPEED DIAPHRAGM VALVE
FOR ATOMIC LAYER DEPOSITION**

Group Art Unit: 3753

Examiner: Kevin L. Lee

Date: April 28, 2005

AMENDMENT

TO THE COMMISSIONER FOR PATENTS:

In response to the December 28, 2004 Office action, please amend the above-identified patent application as follows.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims that begins on page 3 of this paper.

Remarks begin on page 9 of this paper.

05/02/2005 NNGUYEN1 00000033 10609134

02 FC:2201	600.00 OP
03 FC:2202	175.00 OP